

Aerosol assisted chemical vapour deposition of transparent conductive ZnO thin films with hexagonal microplate surface and ultrahigh haze value

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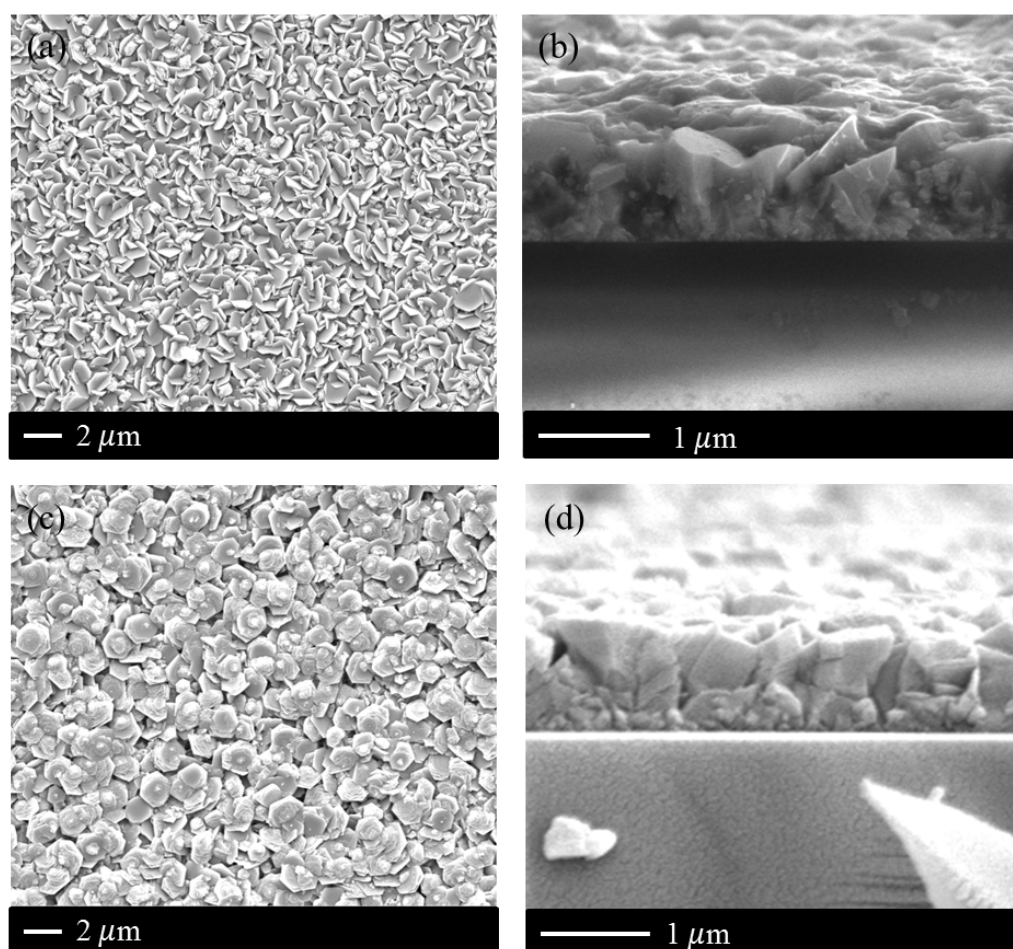


Figure S1 Surface and cross-section SEM images of (a), (b) ZnO-a and (c), (d) ZnO-aw films.

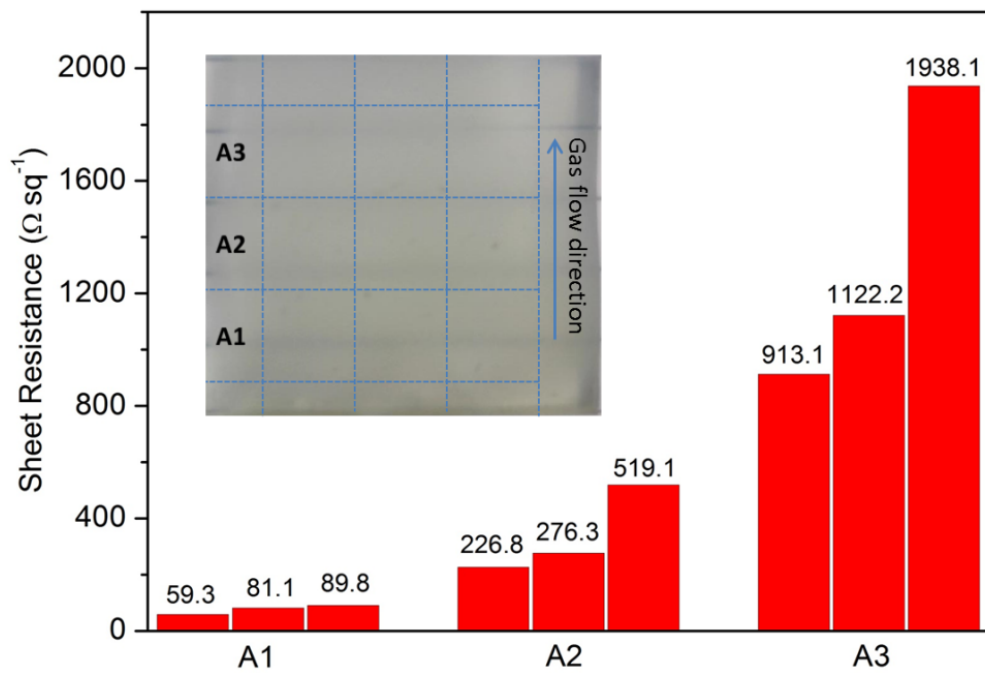


Figure S2 Film conductivity as a function of gas flow distance for a typical ZnO-aw sample.